

Abstract of proposed collection:

The Application for Additional Visa Pages (DS-4085) Form has been developed to replace the Amendment and Validation Application (DS-19) Form. With the introduction of the "electronic passport," it will no longer be possible to amend U.S. passports. The DS-4085 has been developed to serve one of the functions of Form DS-19. Applicants will use the DS-4085 Form to add additional visa pages to their valid U.S. passports. The electronic passport will contain a chip that stores information from the data page of the passport. The information on the data page and that contained on the chip must match. The addition of visa pages will not change information on the data page or alter the chip.

Methodology:

Passport Services collects information from U.S. citizens and non-citizen nationals when they complete and submit the Application for Additional Visa Pages Form. Passport applicants can either download the form from the Internet or obtain one from an Acceptance Facility/Passport Agency. The form must be completed and then signed. The form is then submitted along with the original passport.

Dated: June 17, 2005.

Ann Barrett,

Acting, Deputy Assistant Secretary for Passport Services, Bureau of Consular Affairs, Department of State.

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DEPARTMENT OF STATE

[Public Notice 5124]

30-Day Notice of Proposed Information Collection: Forms DS-573, DS-574, DS-575, and DS-576, Overseas Schools—Grant Request Automated Submissions Program (GRASP), OMB Control No. 1405-0036

ACTION: Notice of request for public comment and submission to OMB of proposed collection of information.

SUMMARY: The Department of State has submitted the following information collection request to the Office of Management and Budget (OMB) for approval in accordance with the Paperwork Reduction Act of 1995.

- *Title of Information Collection:* Overseas Schools Grant Request Automated Submissions Program (GRASP).
- *OMB Control Number:* 1405-0036.
- *Type of Request:* Extension of a currently approved collection.

- *Originating Office:* A/OPR/OS.
- *Form Number:* DS-573, DS-574, DS-575, DS-576.
- *Respondents:* Recipients of grants.
- *Estimated Number of Respondents:* 190.
- *Estimated Number of Responses:* 190.
- *Average Hours Per Response:* 1.50.
- *Total Estimated Burden:* 285 hours.
- *Frequency:* Annually.
- *Obligation to Respond:* Required to retain a benefit.

DATES: Submit comments to the Office of Management and Budget (OMB) for up to 30 days from July 5, 2005.

ADDRESSES: Direct comments and questions to Katherine Astrich, the Department of State Desk Officer in the Office of Information and Regulatory Affairs at the Office of Management and Budget (OMB), who may be reached at 202-395-4718. You may submit comments by any of the following methods:

- *E-mail:* Katherine_T._Astrich@omb.eop.gov. You must include the DS form number, information collection title, and OMB control number in the subject line of your message.
- *Mail (paper, disk, or CD-ROM submissions):* Office of Information and Regulatory Affairs, 725 17th Street, NW., Washington, DC 20503.
- *Fax:* 202-395-6974.

FOR FURTHER INFORMATION CONTACT: You may obtain copies of the proposed information collection and supporting documents from Keith Miller, Office of Overseas Schools, Room H-328, 2401 E Street, NW., Washington, DC 20522-0132, who may be reached on 202-261-8200 or at millerkd2@state.gov.

SUPPLEMENTARY INFORMATION: We are soliciting public comments to permit the Department to:

- Evaluate whether the proposed information collection is necessary to properly perform our functions.
- Evaluate the accuracy of our estimate of the burden of the proposed collection, including the validity of the methodology and assumptions used.
- Enhance the quality, utility, and clarity of the information to be collected.
- Minimize the reporting burden on those who are to respond, including the use of automated collection techniques or other forms of technology.

Abstract of Proposed Collection

The Office of Overseas Schools of the Department of State (A/OPR/OS) is responsible for determining that adequate educational opportunities exist at Foreign Service Posts for

dependents of U.S. Government personnel stationed abroad, and for assisting American-sponsored overseas schools to demonstrate U.S. educational philosophy and practice. The information gathered enables A/OPR/OS to advise the Department and other foreign affairs agencies regarding current and constantly changing conditions, and enables A/OPR/OS to make judgments regarding assistance to schools for the improvement of educational opportunities.

Methodology

Information is collected via electronic media.

Dated: June 20, 2005.

Paula S. Lader,

Deputy Director, Bureau of Administration, Department of State.

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DEPARTMENT OF TRANSPORTATION

Pipeline and Hazardous Materials Safety Administration

Office of Hazardous Material Safety; Notice of Delays in Processing of Exemption Applications

AGENCY: Pipeline and Hazardous Materials Safety Administration, DOT.

ACTION: List of applications delayed more than 180 days.

SUMMARY: In accordance with the requirements of 49 U.S.C. 5117(c), PHMSA is publishing the following list of exemption applications that have been in process for 180 days or more. The reason(s) for delay and the expected completion date for action on each application is provided in association with each identified application.

FOR FURTHER INFORMATION CONTACT: Delmer Billings, Office of Hazardous Materials Exemptions and Approvals, Pipeline and Hazardous Materials Safety Administration, U.S. Department of Transportation, 400 Seventh Street, SW., Washington, DC 20590-0001, (202) 366-4535.

Key to "Reason for Delay"

1. Awaiting additional information from applicant.
2. Extensive public comment under review.
3. Application is technically complex and is of significant impact or precedent-setting and requires extensive analysis.
4. Staff review delayed by other priority issues or volume of exemption applications.